



MBW100T120PHF

1200V Field stop High Ruggedness version IGBT Data sheet

General Descriptions

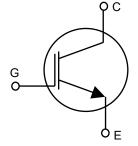
This IGBT is produced using advanced Magnachip's Field Stop Trench IGBT Technology, which provides low $V_{\text{CE}(\text{SAT})}$, high switching performance and excellent quality.

Features

- 1200V Trench + Field stop technology
- Low switching losses
- Positive temperature coefficient
- High Input Impedance

Applications

- High power & High Ruggedness drives
- Motor driver



Chip Type	V _{CE}	IC(Note 1, 2)	Die Size	Package
MBW100T120PHF	1200V	100A	9.588 X 10.490 mm ²	Sawn on foil

Mechanical Parameters

Parameter	Condition/ Material	Value	Unit	
Die size	LxW	9.588 x 10.49	mm²	
Scribe lane	Width	0.1	mm²	
Emitter pad size	-	See chip drawing	mm ²	
Gate pad size	LxW	1.578 x 0.84	mm²	
Thickness		133±5	um	
Wafer size		190	mm	
Net die		242	EA	
Pad metal	AlSiCu	4000	nm	
Backside metal	Al/Ti/Ni/Ag	1600	nm	
Passivation frontside		Polyimide		
Die bond		Conductive epoxy glue and soft solder		
Wire bond		Al< 500um		
Reject die identification		Mapping or Inking		
Storage environment		Sawn on foil product is intended for immediate use and has a limited shelf life, this is based on standard condition temperature atmosphere below 25 °C		

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Absolute Maximum Ratings

Parameter	Symbol	Rating	Unit
Collector-emitter voltage T _{vj} =25 °C	Vce	1200	V
Gate-emitter voltage	V_{GE}	±20	V
DC collector current, limited by T _{vj max}	Ic	(Note 2)	Α
Pulsed collector current, t _p limited by T _{vj max} (Note 3)	IC, Pulse	300	Α
Short circuit data V _{GE} =15V, V _{CC} =800V, T _{vj} =150 °C(Note 3)	t _{sc}	10	μs
Operating Junction temperature	T _{vj}	-40~175	°C

Note 1: nominal collector current at $T_C=100\,^{\circ}C$, not subject to production test-verified by design/characterization

Note 2: depending on thermal properties of assembly

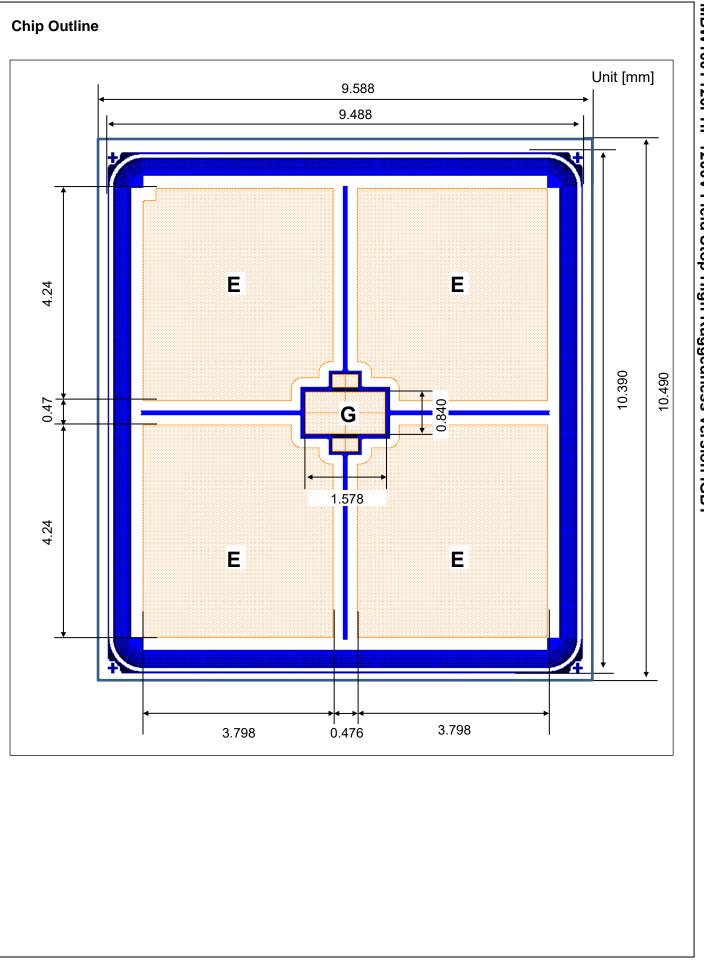
Note 3: not subject to production test - verified by design/characterization

Static Characteristics (T_{vj} =25°C unless otherwise specified and Tested on wafer)

Parameter	Symbol	Test Condition	Min.	Тур.	Max.	Unit.
Collector-emitter breakdown voltage	BVces	Ic = 5mA, V _{GE} = 0V	1200	-	-	V
Gate-emitter threshold voltage	V _{GE(th)}	Ic = 4mA, VcE = VgE	4.8	-	6.8	V
Zero gate voltage collector current	Ices	V _{CE} = 1200V, V _{GE} = 0V	-	-	10	uA
Gate-emitter leakage current, Forward	I _{GES(F)}	V _{GE} = 20V, V _{CE} = 0V	-	-	120	nA
Gate-emitter leakage current, Reverse	I _{GES(R)}	V _{GE} = -20V, V _{CE} = 0V	-	-	120	nA
Collector-emitter saturation voltage	V _{CE(sat)}	V _{GE} = 15V, I _C = 100A	1.40	1.70	2.10	٧
Integrated gate resistor	r _G			5.0		Ω

Electrical Characteristics (not subject to production test - verified by design / characterization)

Parameter	Symbol	Test Condition	Min.	Тур.	Max.	Unit.
Collector-emitter saturation voltage	V _{CE(sat)}	$I_C = 100A$, $V_{GE} = 15V$, $T_{vj} = 150$ °C		2.10		V
Input capacity	C _{ies}	f = 1MHz, T _{vj} = 25°C, V _{CE} =25V		5700		pF
Reverse transfer capacitance	Cres			360		pF



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